

## CASE HU/1-21867/US/A/PCT

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE PCT NATIONAL STAGE APPLICATION OF

DIETMAR HÜGLIN ET AL

Group Art Unit: 1615

Examiner:

Lakshmi S. Channavajjala

INTERNATIONAL APPLICATION NO. PCT/EP 99/07981 Confirmation No. 3542

FILED: October 21, 1999

FOR: STABILISATION OF BODY-CARE AND

HOUSEHOLD PRODUCTS

U.S. APPLICATION NO: 09/830,787

35 USC 371 DATE: May 1, 2001

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

## **DECLARATION UNDER RULE 132**

Dietmar Hueglin, the undersigned, states:

That I received a Ph.D. in Chemistry from Freiburg University, Freiburg, Germany;

That I have been employed by Ciba Specialty Chemicals Corporation since 1996;

That I have approximately 16 years of chemical research and development experience; that from December 1996 to date I have worked in the Research and Development laboratories of Ciba Specialty Chemicals Corporation;

That I invented the subject matter disclosed in U.S. Pat. Nos. 6,184,375, 6,284,821 and 6,117,997 related to stabilization of personal care products.

Specifically I invented the subject matter related to sun protecting compositions in columns 78-79 and skin and hair applications in column 32, line 45 through column 34, line 8 of U.S. Pat. No. 6,184,375.

I invented the subject matter related to sun protecting compositions in columns 68-69 and skin and hair applications in column 31, line 49 through column 33, line 13 of U.S. Pat. No. 6,284,821.

I invented the subject matter related to skin and hair applications in column 32, line 22 through column 33, line 54 of U.S. Pat. No. 6,117,997.

I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under 18 U.S.C. § 1001, and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

Dietmar Hueglin